

## In the United States Patent and Trademark Office

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Berial Number:	10/708778			
Application filed on:				
Applicant(s):	Baokang Bi			
Application Title:	PATTEN GENERATING SYSTEMS	<del></del>		
Examiner/GAU:			<del></del>	
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		At:	Okemos, Michigan	
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,	and Copies of 25 Cited References			
c/o: Baokang Bi, Ar				
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of 4

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Application Number	10/708778	··		
Filing Date	2004 March 24			
First Named Inventor	Baokang Bi			
Art Unit				
Examiner Name		· · · · · ·		
Attorney Docket Number				

			U. S. PATENT I	DOCUMENTS	
Examiner Initials*	Cite No.1	Document Number  Number-Kind Code <sup>2 (# known)</sup>	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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		FORE	<b>IGN PATENT DOCU</b>	IMENTS		
Examiner Initials*	Cite No. <sup>1</sup>	Foreign Patent Document  Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>5</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages Or Relevant Figures Appear	T <sup>6</sup>
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		WO 03/079116	09-25-2003	Pieter Kruit		
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Substitute for form 1445/119	Application Number	10/708778	
INFORMATION DISCLOSURE	Filing Date	2004 March 24	
STATEMENT BY APPLICANT	First Named Inventor	Baokang Bi	
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		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
		Arnaud Bertsch, et al., "Rapid Prototyping of small size objects", Rapid Prototyping Journal, Vol.6, p259, 2000.	
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INF	ORMATION	DIS	CLOSURE	Filing Date	2004 March 24	
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Substitute for form 144.	3/1 10		Application Number	10/708778	
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		Jahja I. Trisnadi, et al., "Overview and applications of Grating Light Valve (TM) based optical write engines for high-speed digital imaging", Proceedings of SPIE, Vol. 5348, p52, 2004		
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